

Method for structuring a decorative or technical pattern in an
object made of an at least partially transparent amorphous,
semi-crystalline or crystalline material

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Technical field of the invention

The present invention relates to a method for structuring a decorative or technical pattern in the thickness of an object made of an at least partially transparent amorphous, semi-crystalline or crystalline material. The present invention relates more particularly to a structuring method using a mono- or
10 multicharged ion beam.

Technological background of the invention

Engraving a decorative pattern by means of a laser beam in the thickness of an object made of an amorphous or crystalline material is known.
15 For this, a powerful laser whose beam will be focused by means of a lens so as to create a series of points at the desired positions inside the transparent object is used. The lens makes it possible to concentrate the coherent light from the laser on a very small surface, which makes it possible to attain optical power values which exceed the damage threshold and which are
20 sufficient to create microcracks in the transparent object. These microcracks of typically 50 to 150 micrometres in size correspond to the positions where the laser beam has been focused and where the material has melted under the effect of the addition of heat. These microcracks act as scattering centres of the ambient light, which makes it possible to reveal them to the observer's
25 view. It is thus possible to engrave in the thickness of an object made of a transparent material a network of points which will form a two-dimensional pattern. In order to carry out three-dimensional engraving, it is possible to

overlay a plurality of two-dimensional point network so precisely that the resulting pattern gives the impression of having been engraved from a single block.

5 The advantage of the technique briefly described above is that of making it possible to produce two- or three-dimensional patterns in an object made of a transparent material such as an object made of glass or an object made of polymethyl methacrylate (PMMA). These patterns may have a technical function or an aesthetical function. In the field of consumer products, objects made of a transparent material are particularly known wherein, based
10 on a digital file of a photograph, the reproduction of a person's face is engraved, for example. Such products meet certain success with consumers. One of the main drawbacks of this engraving technique is nevertheless the frequently long time required to engrave the patterns in the object made of a transparent material which renders the use thereof in the industrial field
15 problematic.

Summary of the invention

The aim of the present invention is that of remedying the problems mentioned above along with others by providing a method for structuring a
20 pattern in the thickness of an object made of an at least partially transparent material which is particularly rapid and readily automatable.

To this end, the present invention relates to a method for structuring a decorative or technical pattern in the thickness of an object made of an at least partially transparent amorphous, semi-crystalline or crystalline material,
25 the object made of an at least partially transparent material comprising a top surface and a bottom surface which extends away from the top surface, the method comprising the step consisting of providing at least one of the top or bottom surfaces of the object made of an at least partially transparent material with a mask which defines at least one opening the outline thereof
30 corresponding to the profile of the decorative or technical pattern to be

structured, the mask covering the at least one top or bottom surface of the object made of an at least partially transparent material at the positions which are not to be structured, the method also comprising the step which consists of structuring the decorative or technical pattern by means of a mono- or
5 multicharged ion beam through the at least one opening of the mask, the mechanical properties of the mask being sufficient to prevent the ions of the ion beam from etching the at least one top or bottom surface of the object made of an at least partially transparent material at the positions where this surface is covered by the mask.

10 According to one particular embodiment of the method according to the invention, the mono- or multicharged ion beam is produced by a mono- or multicharged ion source of the electron cyclotron resonance (ECR) type.

 According to a further particular embodiment of the method according to the invention, the at least partially transparent object is made of sapphire,
15 ruby or diamond, preferably synthetic.

 According to an even further particular embodiment of the method according to the invention, the at least partially transparent object is made of a semi-crystalline organic material.

20 According to an even further particular embodiment of the method according to the invention, the at least partially transparent object is made of mineral glass or of an amorphous organic material.

 According to an even further particular embodiment of the method according to the invention, the mask is deposited on at least one of the top and bottom surfaces of the object made of an at least partially transparent
25 material:

- either by selective deposition such as ink-jet printing of a masking material at the positions where the mask is to cover that of the top and/or bottom surfaces whereon it is structured;

- or by deposition of a layer of a masking material on the entirety of that of the top and/or bottom surfaces whereon the mask is to be structured, followed by ablation of the masking layer at the positions where that of the top and/or bottom surface is to be structured.

5 According to an even further particular embodiment of the method according to the invention, the masking layer is ablated by means of a laser beam.

 According to an even further particular embodiment of the method according to the invention, the masking layer is an ultraviolet radiation-
10 sensitive resin which is structured by means of a UV source.

 The present invention also relates to an object made of an at least partially transparent amorphous, semi-crystalline or crystalline material in accordance with the method according to the invention. This object may particularly be a glass, a dial or a bezel for a timepiece such as a wristwatch,
15 a middle or a back of a case, a winding-mechanism crown or a push-button head for a timepiece movement, a wristlet link for a watch or a piece of jewellery or indeed a bridge for a timepiece movement.

 The present invention also relates to a portable object, particularly a watchcase, comprising at least one element chosen in the group formed by a
20 glass, a dial, a bridge and a back, this at least one element being made of an at least partially transparent amorphous, semi-crystalline or crystalline material and structured in accordance with the method according to the invention, this element comprising at least one top surface and at least one bottom surface interconnected by an edge, the portable object also
25 comprising a light source, the light source being arranged so as to illuminate the element via the bottom surface thereof or via the edge thereof.

 Owing to these features, the present invention provides a method for selectively structuring a three-dimensional technical or decorative pattern in an object made of an at least partially transparent material by means of a
30 mono- or multicharged ion beam. According to the invention, the term mono-

charged ions denotes ions whose degree of ionisation is equal to +1, and the term multicharged ions denotes ions whose degree of ionisation is greater than +1. The ion beam may comprise ions all having the same degree of ionisation, or may result from a mixture of ions having different degrees of ionisation.

By bombarding through a mask a surface of an object made of an at least partially transparent material by means of an ion beam, it is possible to structure in this object a three-dimensional technical or decorative pattern from the surface and up to a certain depth. Indeed, on striking the object made of an at least partially transparent material, the ions of the ion beam penetrate the object and create cavity or void type defects from a very short distance from the surface of this object, typically of the order of 10 to 15 nanometres, and up to a depth typically between 200 and 500 nanometres.

In a first aspect, if one considers that the defects created by the ions in the object made of an at least partially transparent material are of substantially cubic shape, the length of one side of such a cube is typically of the order of 50 to 200 nanometres. Obviously, the size of the defects created and the depth up to which such defects are created are particularly dependent on the nature of the material of which the object is made, the degree of ionisation of the ions and the velocity with which the ions strike the surface of the object. It is also understood that the size of the defects created in the object decreases from the surface towards the inside of this object. Analyses performed particularly by transmission electron microscopy show that an object made of an at least partially transparent material structured by means of an ion beam in accordance with the method according to the invention exhibits, from the surface towards the inside, a very thin surface layer, of the order of 10 to 15 nanometres, devoid of defects, followed by an amorphous structural layer whose thickness is between 100 and 500 nanometres and wherein defects are formed. Beyond this amorphous structural layer,

practically no further effect of the ion bombardment on the structure of the material of which the object is made is observed.

Among the known ion implantation techniques, one of these consists of bombarding the surface of the object to be treated by means of a mono- or
5 multicharged ion source of the electron cyclotron resonance type. Such a system is also known as Electron Cyclotron Resonance or ECR.

An ECR ion source makes use of electron cyclotron resonance to create a plasma. Microwaves are injected into a low-pressure gas volume to be ionised, at a frequency corresponding to the electron cyclotron resonance
10 defined by a magnetic field applied to a region situated inside the gas volume to be ionised. The microwaves heat the free electrons present in the gas volume to be ionised. These free electrons, under the effect of thermal agitation, will come into collision with the atoms or molecules and induce the ionisation thereof. The ions produced correspond to the type of gas used.
15 This gas may be pure or composite. It may also consist of a vapour obtained from a solid or liquid material. The ECR ion source is capable of producing singly charged ions, i.e. ions whose degree of ionisation is equal to 1, or indeed multicharged ions, i.e. ions whose degree of ionisation is greater than 1.

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Brief description of the figures

Further features and advantages of the present invention will emerge more clearly from the following detailed description of an example of embodiment of the method according to the invention, this example being
25 given merely by way of illustration and not restriction with reference to the appended drawing wherein:

- figure 1 is a schematic view of a mono- or multicharged ion source of the ECR electron cyclotron resonance type according to the prior art;

- figures 2A and 2B are perspective views illustrating the steps of the method according to the invention for structuring by means of a multicharged ion beam a decorative pattern in a surface of an object made of an at least partially transparent material;

5 - figure 3 is a sectional view through the thickness of an object made of sapphire bombarded by means of a nitrogen ion beam;

- figure 4 is a perspective view of a watchcase in various elements whereof are embodied decorative patterns according to the teachings of the method according to the invention;

10 - figures 5A and 5B illustrate two different embodiments of illumination of a decorative pattern in the top surface of a watch glass in accordance with the method according to the invention;

 - figure 6 illustrates a mask embodied in the form of a metal sheet in which an opening whose outline corresponds to the pattern to be structured
15 has been cut;

- figure 7A is a bottom view of the watchcase represented in figure 4;

- figure 7B is a top view of a watch dial in which have been structured a decorative pattern as well as hour indexes which form technical patterns, and

20 - figure 7C is a representation of a bridge for a timepiece movement wherein a decorative pattern has been structured using the method according to the invention.

Detailed description of an embodiment of the invention

25 The present invention proceeds from the general inventive idea which consists of selectively bombarding the surface of an object made of an at least partially transparent material through a mask using a mono- or multicharged ion beam to create in this object a three-dimensional technical

or decorative pattern. The term mono- or multicharged ion beam denotes a beam comprising ions accelerated under the effect of an electric field and exhibiting either all the same degree of ionisation, or exhibiting different degrees of ionisation. The ions strike the surface of the object and penetrate
5 therein up to a certain depth, creating cavity or void type defects, the properties thereof, particularly optical, being different to those of the material which is not affected by the ion bombardment. It is understood that the depth up to which the ions penetrate the object and the dimensions of the defects created are dependent on multiple factors of which mention may be made of
10 the nature of the material of which the at least partially transparent object is made, the mass of the ions, the degree of ionisation of the ions or indeed the velocity at which the ions strike the surface of the object. It is also understood that the features of these defects, namely the dimensions thereof and the depth at which they are found below the surface of the object, determine the
15 physical, particularly optical, properties thereof. In some cases indeed, the three-dimensional technical or decorative pattern structured in the object made of an at least partially transparent material in accordance with the method according to the invention is not perceptible under normal conditions of use, and the presence thereof may only be revealed if the user makes use
20 of the hydrophilic properties of the pattern by spraying a little steam on the surface of the object wherein the pattern has been structured. In other cases, the defects which form the desired technical or decorative pattern act as light scattering centres, such that the pattern is perceptible even under normal brightness conditions, and stands out even more clearly when the object in
25 which this pattern has been structured is illuminated by means of a light source.

A number of ion implantation techniques exist. Within the scope of the present patent application, particular interest is taken in a mono- or multicharged ion source of the ECR electron cyclotron resonance type. Very
30 schematically, and as illustrated in figure 1 appended to the present patent application, an ECR ion source, designated as a whole by the general

reference number 1, comprises an injection stage 2 in which a volume 4 of gas to be ionised and a microwave 6 are introduced, a magnetic confinement stage 8 in which a plasma 10 is created, and an extraction stage 12 for extracting and accelerating the ions of the plasma 10 by means of an anode 12a and a cathode 12b between which a high voltage is applied. At the output thereof, the ECR ion source 1 produces an ion beam 14 which, according to requirements, may comprise ions all exhibiting the same degree of ionisation, or indeed will result from a mixture of ions exhibiting different degrees of ionisation. In a first aspect, the ion acceleration voltage is between 1kV and 1000kV and the implantation dose is between $1 \cdot 10^{15}$ ions.cm⁻² and 10^{18} ions.cm⁻².

An example of an object made of a crystalline transparent material and in which a decorative pattern is produced in accordance with the method according to the invention is illustrated in figures 2A and 2B. Designated overall by the general reference number 16, this object is a glass made of sapphire and intended to close a watchcase from the top. This glass 16 comprises a top surface 18a and a bottom surface 18b which extends away from the top surface 18a and which is connected to the latter along the rim thereof by an edge 20. In the example illustrated in figures 2A and 2B, it has been chosen to structure a decorative pattern 22, in this instance the letter of the Greek alphabet Ω , in the top surface 18a of the glass 16. Obviously, this example is given merely by way of illustration and not restriction, it being understood that it would be possible to structure a pattern in the bottom surface 18b of the glass 16, or even structure a decorative pattern in each of the top 18a and bottom 18b surfaces of the glass 16.

Merely by way of example, the sapphire glass 16 which has been treated in accordance with the method according to the invention is planar. The top 18a and bottom 18b surfaces thereof extend parallel with each other separated by a thickness $e = 2$ mm. After masking the top surface 18a of the glass 16 by means of a mask 24 so as to define an opening 25 the outline

thereof corresponding to the desired decorative pattern 22, the glass 16 is bombarded by means of an ion beam 14 consisting of nitrogen ions having a degree of ionisation +1 to +3. The ion beam 14 is produced by means of an ECR ion source 1 of the type described above with reference to figure 1. The ion acceleration voltage used is 37.5kV and the ion implantation dose is $0.5 \cdot 10^{16}$ ions.cm⁻². It is observed that, under the experimental conditions detailed hereinabove, the decorative pattern 22 is imperceptible under natural ambient brightness conditions, and the presence thereof may only be revealed if the user blows steam towards the top surface 18a of the glass 16.

In the Applicant's opinion, this phenomenon is explained in that the zone of the glass 16 in which is structured the decorative pattern 22 exhibits hydrophilic behaviour. Thus, when the steam falls on the top surface 18a of the glass 16, a thinner layer of water with a lower surface tension is formed in the hydrophilic zone where the decorative pattern 22 has been structured than on the rest of the top surface 18a. The layer of water at the position where the decorative pattern 22 has been structured is therefore optically less diffusive and therefore becomes perceptible by the user.

A second example of embodiment of the method according to the invention is provided with reference to an identical glass 16 to that described above. The decorative pattern 22 structured in the top surface 18a of the glass 16 is also unchanged, only the ion bombardment parameters being modified. In this instance, the glass 16 is bombarded by means of an ion beam 14 consisting of nitrogen ions having a degree of ionisation +1 to +3. The ion beam 14 is produced by means of an ECR ion source 1 of the type described above with reference to figure 1. The ion acceleration voltage used is 37.5kV and the ion implantation dose is $1 \cdot 10^{17}$ ions.cm⁻². It is observed that, under the experimental conditions detailed hereinabove, the decorative pattern 22 structured in the glass 16 is visible to the naked eye in daylight, and stands out even more clearly when the glass 16 wherein this decorative pattern 22 has been structured is illuminated by means of a light source. It is understood that the defects forming the decorative pattern 22 act as light

scattering centres, such that the decorative pattern 22 is perceptible even under normal brightness conditions.

In the two examples detailed above, it is seen that using the same ions and accelerating them with the same voltage, it is possible, by varying only
5 the implanted ion dose, to modify the physical, particularly optical, properties of the decorative pattern 22 obtained. Indeed, with an ion implantation dose of $0.5 \cdot 10^{16}$ ions.cm⁻², the decorative pattern 22 is imperceptible to the naked eye under normal lighting conditions, and the presence thereof is revealed by spraying steam to make use of the hydrophilic properties thereof. In the
10 second case, the ion implantation dose is $1 \cdot 10^{17}$ ions.cm⁻² and makes it possible to create in the glass 16 defects which act as light scattering centres, rendering the decorative pattern 22 perceptible even in daylight. These differences in physical behaviour of the pattern structured in the object made of an at least partially transparent material are explained in that the defects
15 which appear in the object under the effect of the ion bombardment differ by the dimensions thereof and by the concentration thereof per unit of volume.

Figure 3 is a sectional view in the thickness of a sapphire sample 26
bombarded by means of a nitrogen ion beam. On examining this figure, it is observed that the sapphire sample 26 exhibits, from the surface inwards, the
20 following series of layers:

- firstly a very thin, surface layer 28, typically of the order of 7 to 15 nanometres which, surprisingly, is slightly or not affected by the ion bombardment and retains the crystalline structure thereof. An attempt
25 to explain this phenomenon is that, when the nitrogen ions strike the surface of the sapphire sample 26, the nitrogen ions penetrate the sapphire sample 26 taking the lowest-energy path and pass through the cells of the crystallographic silicon structure.
- then, a first amorphous layer 30 the thickness thereof being typically between 50 and 60 nanometres. This first amorphous layer 30 is
30 characterised by cavities 32 the dimensions thereof decreasing as the

nitrogen ions penetrate more deeply into the thickness of the sapphire sample 26. This phenomenon is explained in that the deeper the nitrogen ions penetrate into the thickness of the sapphire sample 26, the lower the velocity thereof and the less damage caused to the crystallographic structure of the sapphire sample 26.

- then, a second amorphous layer 34 devoid of cavities the thickness thereof being of the order of 20 to 30 nanometres. The crystallographic structure of the sapphire is therefore highly disrupted by the ion bombardment up to a depth of approximately 80 to 100 nm under the surface of the sapphire sample 26.
- finally, a final layer 36 of a thickness of the order of 50 to 60 nanometres the crystallinity thereof being disturbed without however the sapphire being rendered amorphous throughout the volume thereof.
- beyond this final layer 36, the sapphire in the volume 38 is found.

In figure 4, a watchcase 40 has been represented merely by way of example some components thereof having been treated in accordance with the method according to the invention. They consist of a bezel 42, a middle 44, a crown 46, a corrector 47 and a wristlet link 48. These various elements are embodied in accordance with the method according to the invention by means of an object made of an at least partially transparent material wherein the structure is crystalline, semi-crystalline or indeed amorphous and wherein the decorative pattern 22 is engraved by means of a mono- or multicharged ion beam.

The glass 16 equipped with the decorative pattern 22 thereof described above extends on top of a dial 50 and closes from the top the case 40 (see figures 5A and 5B). This is the alternative embodiment wherein the defects created by ion bombardment form a decorative pattern 22 which scatters light. To enhance this decorative pattern 22 further, it is envisaged to illuminate the glass 16 by means of a light source 52. This light source 52

may be arranged facing the edge 20 of the glass 16. The light produced by the light source 52 thus penetrates into the thickness of the glass 16 and a portion is extracted from the glass 16 upwards towards the observer 54 scattered by the defects which form the decorative pattern 22, rendering the decorative pattern 22 luminous and very visible. The light source 52 may also be arranged between the dial 50 and the glass 16. The light produced by the light source 52 penetrates the glass 16 either directly, or by being reflected firstly onto the dial 50, then is partially scattered towards the outside of the watchcase 40 by the defects which form the decorative pattern 22, rendering this decorative pattern 22 perfectly visible.

Figure 6 illustrates a mask embodied in the form of a metal sheet 56 in which has been cut an opening 25 the outline thereof corresponding to the decorative pattern 22 to be structured.

Figure 7A is a bottom view of the watchcase 40 represented in figure 4. This watchcase 40 is closed by a back 58 made of an at least partially transparent crystalline, semi-crystalline or amorphous material in which is structured a decorative pattern 22 in accordance with the method according to the invention.

Figure 7B is a top view of the watch dial 50 in which has been structured a decorative pattern 22 in accordance with the method according to the invention. By applying the method according to the invention, in the dial 50 technical patterns 60 have also been structured, in this instance four hour indexes at twelve o'clock, three o'clock, six o'clock and nine o'clock.

Figure 7C is a representation of a bridge 62 for a timepiece movement wherein a decorative pattern 22 has been structured using the method according to the invention.

It is obvious that the present invention is not restricted to the embodiments described above, and that various modifications and simple alternative embodiments may be envisaged by those skilled in the art without leaving the scope of the invention as defined by the appended claims.

It shall be noted in particular that the mask may be presented in the form of a metal sheet in which the outline of the pattern to be structured has been cut, this metal sheet being subsequently fastened onto that of the surfaces of the object in which it is sought to structure the pattern. Similarly,
5 the mask may also be made of ceramic. The mask may also be obtained by selective deposition such as ink-jet printing of a masking material at the positions where the mask is to cover that of the top and/or bottom surfaces wherein it is sought to structure the pattern. The mask may also be obtained by deposition of a layer of a masking material on the entirety of that of the top
10 and/or bottom surfaces of the object in which it is sought to structure the pattern. This masking layer is subsequently ablated at the positions where it is sought to structure the pattern in the thickness of the object, for example by means of a laser beam. The mask may also be obtained by means of a layer of light-sensitive resin, for example sensitive to ultraviolet radiation, and
15 be structured by means of a light source, for example ultraviolet. In any case, the mask must exhibit mechanical properties such that the ion beam does not succeed in etching the surface of the object made of an at least partially transparent material in which the pattern is to be structured at the positions where the object is covered by the mask.

20 The term transparent material denotes a material which, by allowing light to pass through readily, makes it possible to distinguish objects clearly through the thickness thereof.

The term object made of an at least partially transparent material denotes an object made of a block of material which has at least one
25 transparent zone in which the technical or decorative pattern is to be structured in accordance with the method according to the invention, the other zones of the objects optionally being opaque.

The term glass denotes a non-crystalline solid which exhibits the vitreous transition phenomenon.

The at least partially transparent material of which the object in which the technical or decorative pattern is structured in accordance with the method according to the invention is made may be chosen from crystalline, semi-crystalline or amorphous. Of the crystalline materials which are well suited to the needs of the invention, mention may be made of sapphire, ruby or diamond. Using the natural form of these jewels may be envisaged, but it shall be understood that the use of synthetically obtained sapphire, ruby or diamond is more realistic in an industrial production context. In the field of amorphous materials, an example of material well suited to the needs of the invention is provided by mineral glass. Further examples of semi-crystalline or amorphous materials which are suitable for the implementation of the method according to the invention are provided by polypropylene homopolymer, polypropylene copolymer and polyethylene terephthalate which are semi-crystalline transparent thermoplastic materials, as well as by crystal polystyrene and polymethyl methacrylate which are amorphous thermoplastic materials.

Reference list

1. ECR ion source
2. Injection stage
4. Gas volume to be ionised
- 5 6. Microwave
8. Magnetic confinement stage
10. Plasma
12. Extraction stage
- 12a. Anode
- 10 12b. Cathode
14. Ion beam
16. Glass
- 18a. Top surface
- 18b. Bottom surface
- 15 20. Edge
22. Decorative pattern
- e. Thickness
24. Mask
25. Opening
- 20 26. Sapphire sample
28. Surface layer
30. First amorphous layer
32. Cavities
34. Second amorphous layer

- 36. Final layer
- 38. Volume
- 40. Watchcase
- 42. Bezel
- 5 44. Middle
- 46. Crown
- 47. Corrector
- 48. Link
- 50. Dial
- 10 52. Light source
- 54. Observer
- 56. Metal sheet
- 58. Back
- 60. Technical pattern
- 15 62. Bridge

CLAIMS

1. Method for structuring a decorative or technical pattern (22, 60) in the thickness of an object made of an at least partially transparent
5 amorphous, semi-crystalline or crystalline material, the object made of an at least partially transparent material comprising a top surface (18a) and a bottom surface (18b) which extends away from the top surface (18a), the method comprising the step consisting of providing at least one of the top (18a) or bottom (18b) surfaces of the object made of an at least partially
10 transparent material with a mask (24) which defines at least one opening (25) whose outline corresponds to the profile of the decorative or technical pattern (22, 60) to be structured, the mask (24) covering the at least one top (18a) or bottom (18b) surface of the object made of an at least partially transparent material at the positions which are not to be structured, the
15 method also comprising the step which consists of structuring the decorative or technical pattern (22, 60) by means of a mono- or multicharged ion beam (14) through the at least one opening (25) of the mask (24), the mechanical properties of the mask (24) being sufficient to prevent the ions of the ion beam (14) from etching the at least one top (18a) or bottom (18b)
20 surface of the object made of an at least partially transparent material at the positions where this top (18a) or bottom (18b) surface is covered by the mask (24).

2. Method according to claim 1, characterised in that the mono- or multicharged ion beam (14) is produced by a mono- or multicharged ion
25 source (1) of the ECR electron cyclotron resonance type.

3. Method according to claim 1, characterised in that the at least partially transparent object is made of natural or synthetic sapphire, ruby or diamond.

4. Method according to claim 2, characterised in that the at least partially transparent object is made of natural or synthetic sapphire, ruby or diamond.

5. Method according to claim 1, characterised in that the at least
5 partially transparent object is made of a semi-crystalline organic material.

6. Method according to claim 2, characterised in that the at least partially transparent object is made of a semi-crystalline organic material.

7. Method according to claim 1, characterised in that the at least partially transparent object is made of mineral glass or of an amorphous
10 organic material.

8. Method according to claim 2, characterised in that the at least partially transparent object is made of mineral glass or of an amorphous organic material.

9. Method according to one of claims 1 to 5, characterised in that
15 the mask (24) is a sheet of material in which the outline of the decorative or technical pattern (22, 60) has been cut, this sheet of material being subsequently fastened onto that of the top (18a) and/or bottom (18b) surfaces of the object in which it is sought to structure the pattern (22, 60).

10. Method according to claim 9, characterised in that the mask (24)
20 is made of metal or of ceramic.

11. Method according to one of claims 1 to 5, characterised in that the mask (24) is obtained by selective deposition of a masking material at the positions where the mask (24) is to cover that of the top (18a) and/or bottom (18b) surface at the positions where this top (18a) and/or
25 bottom (18b) surface is not to be struck by the ion beam (14).

12. Method according to claim 11, characterised in that the mask is produced by ink-jet printing.

13. Method according to one of claims 1 to 5, characterised in that the mask (24) is obtained by deposition of a layer of a masking material on that of the top (18a) and/or bottom (18b) surfaces whereon the mask (24) is to be structured, followed by ablation of the masking layer at the positions
5 where that of the top (18a) and/or bottom (18b) surface is to be structured.

14. Method according to claim 13, characterised in that the layer of masking material is ablated by means of a laser beam.

15. Method according to claim 14, characterised in that the masking material is an ultraviolet radiation-sensitive resin which is structured by
10 means of a UV source.

16. Object obtained by implementing the method according to one of claims 1 to 15.

17. Object according to claim 16, characterised in that it consists of:

- a glass (16), a dial (60) or a bezel (42) for a timepiece such as a
15 wristwatch;
- a middle (44) or a back (58) of a watchcase (40);
- a crown (46), a corrector head (47) or a bridge (64) for a timepiece movement, or
- a wristlet link (48) for a watch or a piece of jewellery.

20 18. Portable object, particularly a watchcase (40), comprising at least one element chosen in the group formed by a glass (16), a dial (60), a bezel (42), a middle (44), a back (58), a crown (46), a corrector head (47), a bridge (64) and a wristlet link (48), this at least one element being made of an at least partially transparent amorphous, semi-crystalline or crystalline material
25 and structured in accordance with the method according to any one of claims 1 to 15, this element comprising at least one top surface and at least one bottom surface interconnected by an edge, the portable object also

comprising a light source (52), the light source (52) being arranged so as to illuminate the element via the bottom surface thereof or via the edge thereof.